

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: SOO-SUK LEE, ET AL.

FOR: MICROARRAY SUBSTRATE COMPRISING PATTERNED PHOTORESIST  
FILM WITH SPOT REGIONS, MICROARRAY, AND METHOD OF  
DETECTING TARGET MATERIAL

**PRELIMINARY AMENDMENT**

Mail Stop Patent Application  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Prior to the Examiner acting in the above-referenced application, please  
preliminary amend the above-identified application as follows.